

**Al<sub>2</sub>O<sub>3</sub> – Si<sub>3</sub>N<sub>4</sub> –**

Al<sub>2</sub>O<sub>3</sub> – Si<sub>3</sub>N<sub>4</sub> – ,

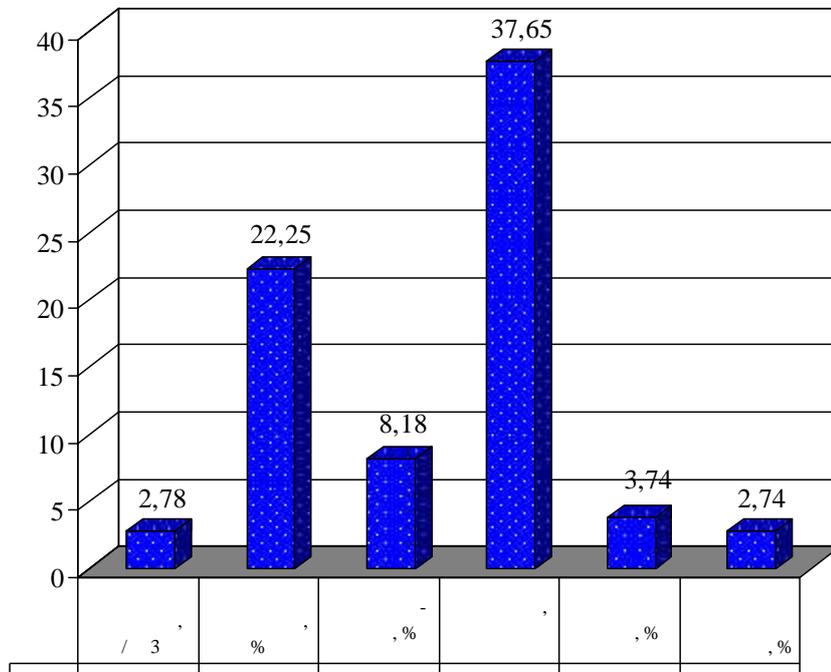
2,6–2,8 / 3,

12–38 ,

800 ° – 4–12 %,  
– 3,5–10,5 %.

( Al<sub>2</sub>O<sub>3</sub> – Si<sub>3</sub>N<sub>4</sub> –

18–27 %,



5 . % , 0,5 . % 90 . % Al<sub>2</sub>O<sub>3</sub>, 5 . % Si<sub>3</sub>N<sub>4</sub>,  
( 100 %)